

Electrochemical Characterization of Rapid Discharge Sintering (RDS) NiO Cathodes for Dye-Sensitized Solar Cells of *p*-Type

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Received 27 December 2014; accepted 16 January 2015; published 21 January 2015

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Abstract

Nickel oxide (NiO) thin films with thickness ranging in the interval 0.2 - 3.5 μm have been deposited onto conductive transparent substrate via the method of plasma-assisted rapid discharge sintering (RDS) with microwave heating starting from NiO nanoparticles with diameter 50 nm. The optical and electrochemical properties of the RDS NiO films in the pristine state were characterized in non aqueous electrolyte with the solvent 3-methoxy-propionitrile (3-MPN). Upon electrochemical cycling of NiO in 3-MPN we observed two characteristic oxidation peaks referring to the two nickel centred processes Ni(II)→Ni(III) and Ni(III)→Ni(IV), which are both localized prevalently on the surface of the metallic oxide. The oxide films prepared with the RDS method were also sensitized with different types of commercial dyes, either organometallic (N719, black dye) or organic (squaraine 2, erythrosine B), to compare the corresponding *p*-type dye-sensitized solar cells (*p*-DSCs). All dyes here employed matched the energies of their frontier orbitals with the upper edge of NiO valence band and the redox level of the triiodide/iodide couple. The comparison of the performances of the *p*-DSCs based on RDS NiO which differed exclusively for the nature of the sensitizer showed that the extent of electronic conjugation in the structure of the dye is crucial for the control of the photovoltaic performance of the corresponding *p*-DSC.

Keywords

Nickel Oxide, Dye-Sensitized Solar Cell, Solar Energy Conversion, *p*-Type

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1. Introduction

Nickel oxide (NiO) is a chemically stable material with semiconducting properties of *p*-type, [1] which is used as electroactive component in several important technologies ranging from batteries [2] to electrochromic windows, [3] [4] and, more recently, from water splitting electrolyzers [5] [6] to dye-sensitized solar cells (DSCs) [7] [8] among others [9]. Such a wide applicability of NiO relies on the possibility of modulating its electrical conductivity and optical transmission (when in the configuration of transparent thin films with thickness $l < 3 \mu\text{m}$) in a controlled fashion by means of electrical fields, chemical/electrochemical doping [3] [4] or irradiation in the UV-visible spectrum [10]. In particular, the utilization of NiO as alternative cathodic material in DSCs (also known as Grätzel cells) [11] has encouraged since the early years of 2000 [12] the development of preparation procedures [7] [13] [14] and deposition methods [15] for the realization of mesoporous and conductive *p*-type NiO electrodes in conjunction with the design and the synthesis of appropriate sensitizers [16] [17] that would impart efficient and fast photoinjection of holes from the valence band (VB) of the oxide to the excited dye. This combination of functional materials in a DSC leads to the desired effect of the photoactivated reduction of the oxidized form of the redox shuttle provided that at the anode occurs the reverse process at a comparable rate [12]. Historically DSCs employed the anode (made of *n*-type TiO_2 [11] or, less commonly, ZnO [18]) as the sole photoactive component of the solar cell. In this conventional configuration the cathode of the DSC is constituted by a transparent metallic conductor like fluorine-doped tin oxide (FTO) or indium-doped tin oxide (ITO), covered with metallic nanoparticles that act exclusively as electrocatalytic centres for the reduction of the oxidized form of the redox shuttle while preserving the optical transparency of the substrate [19]. In this context some authors suggested that the replacement of such photoelectrochemically inert cathodes with a *p*-type metal oxide rendered photoactive by dye-sensitization would have improved the performances of DSCs by enhancing the light conversion efficiency [12]. Such an approach led to the definition and the design of tandem DSCs with both electrodes photoactive in the visible-NIR spectrum utilizing a combination of opportune dyes with complementary optical absorption [12]. Tandem DSCs generally ameliorate their photovoltage characteristics compared to the conventional DSCs with a single photoactive component, while lose in current density due to the still lacking matching of the current flows in the best performing sensitized anodes and sensitized cathodes. The latter electrodes defect generally of relatively poor charge injection efficiency [17], high but non utilizable optical self-absorption in the non-sensitized state [20], and trapping of the photoinjected charge caused by the frequent occurrence of redox reactions within *p*-type oxides which are characterized by mixed valence [21]. These drawbacks call for improvements in many directions of research related with NiO structure and morphology, its sensitization, and the resulting photoelectrochemical properties. In the present work we consider the characterization of the optical and photoelectrochemical properties of the NiO films obtained via the method of rapid discharge sintering (RDS) in plasma atmosphere [20] when RDS NiO is in the pristine state and operates in non-aqueous electrolyte. The choice of plasma assisted sintering of NiO nanoparticles as method of sample preparation was motivated by the earlier recognition that this method leads to the production of thin films with high porosity and mechanical stability as required to the electrodes for DSCs [15]. These features achieved through the RDS method allow the penetration of the electrolyte throughout the whole layer of the oxide for a higher efficiency of charge photoinjection, and warrant charge transport throughout the whole oxide layer due to the electrical connectivity between adjacent NiO nanoparticles and between the NiO coating and the conductive substrate generated by this modality of sintering. Further to that we have also considered the comparative characterization of the *p*-DSCs derived from the sensitization of RDS NiO with the series of commercial dyes N719, black dye (BD), squaraine 2 (SQ2), and erythrosine B (ERY B) (Figure 1) utilizing the same type of NiO cathode.

2. Experimental Section

For the deposition of NiO 50 nm nanoparticles of the metal oxide (99.8% grade from Sigma-Aldrich) were suspended in 2-propanol at a concentration of $20 \text{ g}\cdot\text{L}^{-1}$ to give a slurry for the step of spray deposition. Prior to NiO deposition the glass substrates ($2 \times 2 \text{ cm}^2$) were ultrasonically cleaned for 5 min in methanol followed by acetone. The NiO particulate layer was spray-deposited onto fluorine doped tin oxide (FTO) coated glass ($12 \Omega\cdot\text{sq}^{-1}$, 3 mm thick) supplied by Solaronix, using the technique reported in Ref. [22] The FTO-covered glass substrate was kept at room temperature during the spraying of NiO nanoparticles [23]. The area of the NiO samples was $5 \times 5 \text{ mm}^2$. The microwave plasma sintering process known as rapid discharge sintering (RDS), was carried out

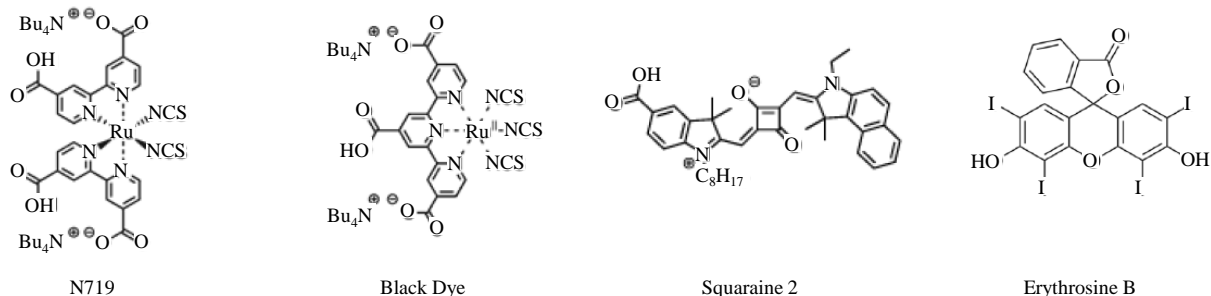


Figure 1. Chemical structure of the four dyes utilized for sensitizing the samples of NiO obtained via microwave sintering in plasma atmosphere.

using a circumferential antenna plasma (CAP) microwave system according to a procedure described in detail in Ref. [24]. Plasmas were formed at a pressure of 5 mbar in an Ar and O₂ (volume ratio: 10/1) atmosphere. For the formation of plasma input powers of 2.4 kW were used. The input power was generated by a Mugge microwave power supply operating at a frequency of 2.45 GHz. Substrate temperatures were measured *in-situ* during the thermal processing of the substrate using a LASCON QP003 two-colour pyrometer from Dr. Mergenthaler GmbH & Co. For plasma-assisted microwave sintering three NiO samples were treated simultaneously at a temperature of ~450°C with a treatment time of 5 min [15]. Thickness values for the sintered NiO films are given within a broad range of 1 μm (*vide infra*). This is because the thicker samples obtained with multiple passes of spraying displayed generally a nonuniform thickness [23].

The electrochemical properties of bare NiO thin films ($0.2 \leq l \leq 3.5 \mu\text{m}$) were studied using a custom-made cell with a three-electrode configuration: NiO-covered FTO was the working electrode, a Pt wire was the counter electrode, and Ag/AgCl was used as reference electrode. The electrolytes were 0.2 M LiClO₄ in 3-methoxy-propionitrile (3-MPN), and 0.2 M KCl, 0.01 M KH₂PO₄, 0.01 M Na₂HPO₄ in H₂O. All chemicals were purchased from Sigma-Aldrich and were used as received. The applied potential values here reported are all referred to the Ag/AgCl electrode (E vs NHE = 0.21 V). Cyclic voltammeteries and chronoamperometric curves were recorded with the potentiostat/galvanostat Autolab PGSTAT 128N, and analyzed with the software NOVA 1.9.

The sensitisation of plasma sintered NiO was carried out by immersing NiO in the ethanol solution of N719 (0.1 mM), BD (0.1 mM), and ERY B (0.3 mM) for 24 h in the dark and keeping the solution temperature at 60°C. In the case of NiO sensitization with SQ2 the dipping time of the electrode in the tincture solution (0.1 mM in ethanol) was 7 h. Dark conditions and the temperature of 60°C were maintained also for NiO sensitization with SQ2.

Optical spectra were taken with a spectrophotometer Cary 50, from Varian-Agilent Technologies.

The procedure for the mounting and assembly of the NiO-based dye-sensitized solar cells (DSCs) has been reported in Ref. [25]. For the determination of the characteristic JV curves for the four different *p*-DSCs the intensity of the incident light (I_{in}) from the sun simulator was 8.35 W·m⁻².

3. Results and Discussion

3.1. Electrochemical Properties of RDS NiO

The cyclic voltammogram of microwave sintered NiO in non aqueous electrolyte (LiClO₄ 0.2 M in 3-MPN) at different scan rates presents two broad oxidation waves with reversible features (Figure 2) as observed also when NiO is cycled in aqueous electrolyte [20] [26] [27].

This result indicates that the processes of Ni oxidation in non aqueous electrolyte are of the same nature of those occurring in aqueous electrolyte [26]. When the oxidation peak at lower potential value (the one in the range 0.3 - 0.5 V vs Ag/AgCl) is considered, the non-hydrated nickel oxide compensates the positive charge mostly accumulated on Ni sites with the uptake of perchlorate anions as follows:



This evidences a behaviour typical of an intercalation material [28]-[31]. When the second oxidation peak at

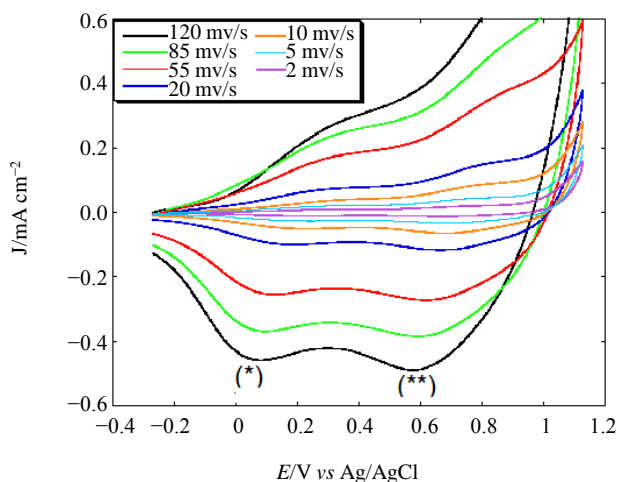
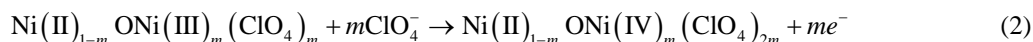


Figure 2. Cyclic voltammograms of NiO (thickness: 0.6 μm) at seven different scan rates ranging from 2 to 120 $\text{mV}\cdot\text{s}^{-1}$. Electrolyte: LiClO_4 0.2 M in 3-MPN.

larger potential values (*i.e.* the one comprised in the range 0.6 - 1.0 V vs Ag/AgCl, **Figure 2**) is considered, the mechanisms of charge compensation is



In the case of Equation (2), the formation of species containing predominantly Ni(IV) is involved [32] [33]. The dependence of the current peak values with the scan rate was evaluated for the two cathodic peaks of NiO within the range $-0.4 \leq E \leq 1.2$ V vs Ag/AgCl. These have been indicated with (*) and (**) in **Figure 2**. The linear trend of the current peaks with the scan rate of the cyclic voltammetry (**Figure 3**) denotes the occurrence of redox processes in NiO, which are surface confined when NiO is undergoing electrochemical oxidation in non aqueous electrolyte [34].

In a successive experiment the electrochemical behavior of the same sample of NiO was recorded in both non aqueous and aqueous electrolytes according to the succession: TEST 1, electrolyte 0.2 M LiClO_4 in 3-MPN; TEST 2, electrolyte 0.2 M KCl, 0.01 M KH_2PO_4 , 0.01 M Na_2HPO_4 in H_2O ; TEST 3, electrolyte 0.2 M LiClO_4 in 3-MPN, in order to assess the effect of surface hydration on the redox properties of NiO (**Figure 4**). In non aqueous environment pristine NiO displays the voltammogram with the lowest current density values (Cycle 1, **Figure 4**). Under these circumstances the mechanism of charge compensation accompanying the oxidation of NiO is based exclusively on the exchange of ClO_4^- anions between the oxide surface and the electrolyte (Equations (1) and (2)). This is because ClO_4^- is the sole negatively charged species present in the non aqueous environment here considered. The successive electrochemical cycling in water electrolyte (Cycle 2, **Figure 4**) brings about an increase of the current density exchanged by the NiO with respect to pristine NiO in organic electrolyte (Cycle 1, **Figure 4**). Such a behaviour is primarily attributed to the formation of a hydrated NiO surface upon contact of NiO with the aqueous electrolyte, and the occurrence of charge compensation mechanisms with the release of hydrogen cations [26]. Upon hydration of NiO in aqueous environment we suppose that the number of protons which are available for charge exchange on hydrated NiO surface, is higher than the maximum number m of ClO_4^- anions (see Equation (1)) that NiO can either host in its oxidized structure [28] [29] or adsorb on its oxidized surface. Such a hypothesis is supported by the further increase of the current densities with respect to the voltammetry of NiO in the pristine state (Cycle 1, **Figure 4**) when NiO is cycled for the second time in organic electrolyte (Cycle 3, **Figure 4**) immediately after the cycle in water electrolyte (Cycle 1, **Figure 4**). The similarity of the current profiles of Cycles 2 and 3 (**Figure 4**) indicates that the hydrogen cation intervenes in the mechanisms of charge compensation (Equations (1) and (2)) also in organic electrolyte when NiO surface is hydrated, *i.e.* after the realization of Cycle 2 (**Figure 4**) conducted in aqueous electrolyte.

Despite the increase of the amount of charge exchanged by NiO in aqueous environment with respect to the organic solvent 3-MPN (**Figure 4**), the electrochemical stability of NiO results much higher in the non aqueous environment (**Figure 5**) [26].

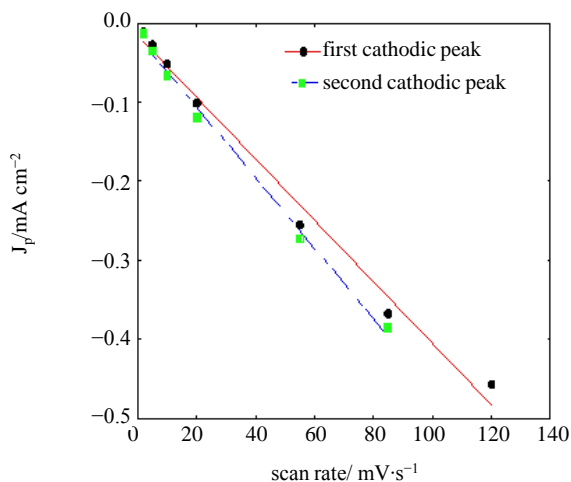


Figure 3. Linear dependence of the cathodic peak currents (J_p) with the scan rate for the two redox processes of NiO (data extracted from Figure 2). Electrolyte: LiClO_4 0.2 M in 3-MPN. First and second cathodic peak refer respectively to the peaks (*) and (**) indicated in Figure 2.

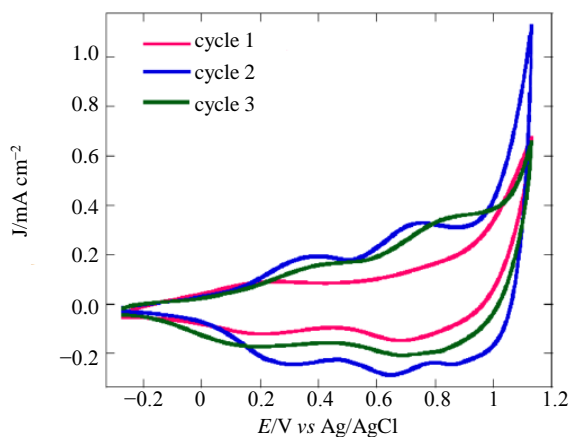


Figure 4. Cyclic voltammograms of NiO (thickness: $0.6 \mu\text{m}$) at $20 \text{ mV}\cdot\text{s}^{-1}$ in different electrolytes. Cycle 1 refers to the first cyclic voltammogram of NiO recorded in the non aqueous electrolyte 0.2 M LiClO_4 in 3-MPN. Cycle 2 refers to the cyclic voltammogram of NiO in the aqueous electrolyte 0.2 M KCl , 0.01 M KH_2PO_4 , 0.01 M Na_2HPO_4 recorded immediately after Cycle 1. Cycle 3 refers to the cyclic voltammogram of NiO recorded in 0.2 M LiClO_4 in 3-MPN immediately after Cycle 2.

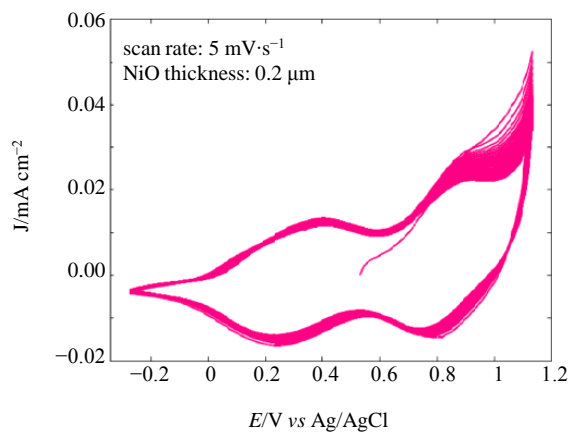


Figure 5. Continuous cycling of NiO (thickness: $0.2 \mu\text{m}$) at $5 \text{ mV}\cdot\text{s}^{-1}$ with the organic electrolyte 0.2 M LiClO_4 in 3-MPN.

The comparison between the second and 100th cycle in 3-MPN electrolyte (**Figure 6**) shows that the extent of the surface-localized processes of NiO oxidation is not affected by continuous electrochemical cycling. This is somewhat in contrast with what we found in precedence when NiO was cycled in aqueous electrolyte, because continuous cycling led to the almost complete disappearance of the current associated with the oxidation of NiO thin film, due to the occurrence of a dissolution process introduced by extensive surface charging [31] in presence of the polar solvent H₂O [26]. The improved electrochemical stability in the non aqueous electrolyte was extremely encouraging in the perspective of utilizing these NiO films as *p*-type photoelectrodes for water-free devices like dye-sensitised solar cells (DSCs) [11] [34] [35]. The NiO electrodes here considered possessed mesoporous features useful for DSC purposes [15] [26], since the increase of film thickness brought about the corresponding increase of the current density exchanged by electroactive NiO (**Figure 7**) [20].

3.2. NiO Sensitization and DSC Performance

The optical spectrum of plasma sintered NiO deposited onto FTO substrate is shown in **Figure 8**.

The intrinsic absorption of NiO in the near UV-visible range (**Figure 8**) proved to be not useful for the photoactivation of the electrochemical processes of Equations (1) and (2) based on pristine RDS NiO (**Figure 2**, **Figure 5** and **Figure 6**) as verified when NiO electrode was irradiated with white light (**Figure 9**). The lack of any photoelectrochemical processes in bare NiO is proven by the fact that the voltammograms are practically unvaried in passing from the dark to the illuminated state for non-sensitized plasma sintered NiO (**Figure 9**). Any photoconduction or a photovoltaic effect would have manifested itself with the increase of the current or a shift of the potential at which NiO oxidation takes place under NiO illumination [34].

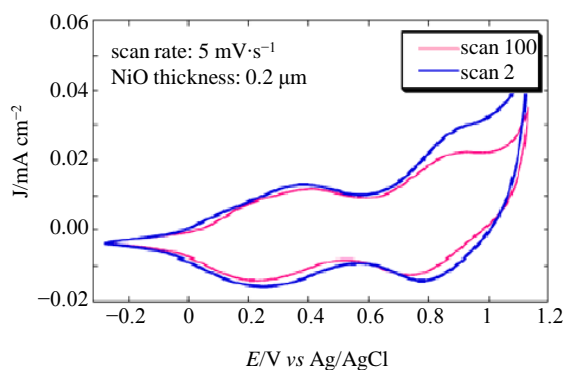


Figure 6. Comparison of the second and 100th voltammetric cycle (data extracted from **Figure 5**).

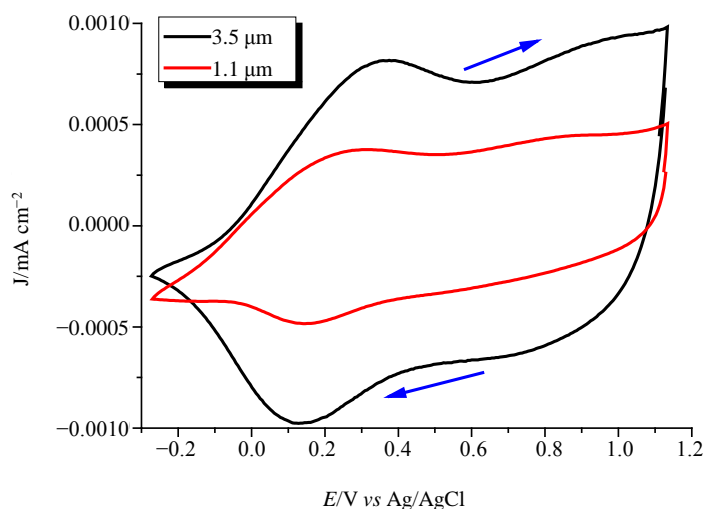


Figure 7. Cyclic voltammograms of NiO samples with two different thicknesses at the scan rate 20 mV·s⁻¹. Electrolyte: 0.2 M LiClO₄ in 3-MPN. Blue arrows indicate the verse of potential scan.

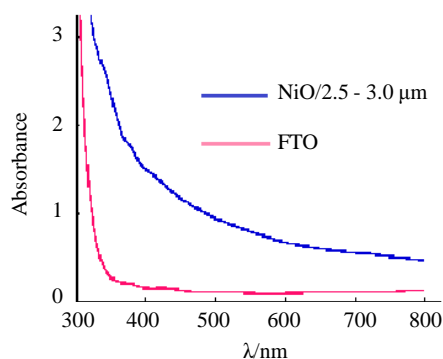


Figure 8. Optical spectra of glass/FTO substrate and glass/FTO/NiO film (blank: air). NiO film thickness: 2.5 - 3.0 μm .

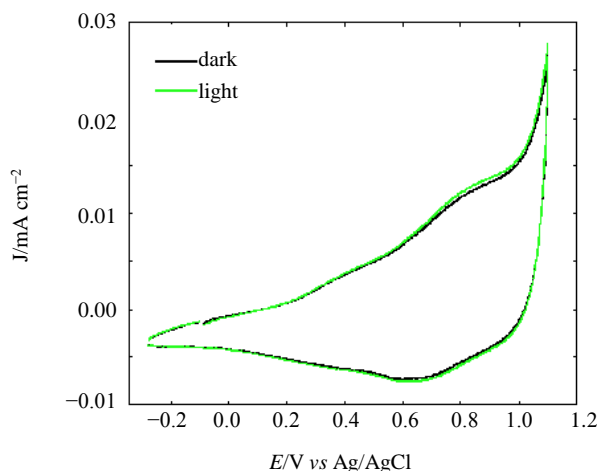


Figure 9. Cyclic voltammograms of NiO in 0.2 M LiClO_4 in 3-MPN in the dark conditions and under white light irradiation. NiO film thickness: 0.2 μm ; scan rate: 20 $\text{mV}\cdot\text{s}^{-1}$. Intensity of the incident white light: 16 $\text{W}\cdot\text{m}^{-2}$. Average transmittance of NiO sample in the visible spectrum: 80%.

For their employment as photoactive cathodes in *p*-DSCs, RDS NiO films were sensitized with the commercial dyes N719, BD, SQ2 and ERY B (Figure 1). With the exception of ERY B, the other three dyes N719, BD and SQ2 are typically utilized for the sensitization of TiO_2 [35]. Anyhow, all of them can be used for NiO sensitization since possess energy levels of the frontier orbitals which match opportunely with the upper edge of the VB of NiO [36]. This allows the photoinduced injection of holes from the excited dye to the oxide VB [36]. The absorption spectra of NiO sensitized with the four different dyes are shown in Figure 10 (the spectra of the tincture solutions are presented in the supplementary information). The choice of a relatively thin film of NiO ($l < 1.5 \mu\text{m}$) for the assembly of the *p*-DSC was dictated by the strong intrinsic optical absorption of thicker NiO (Figure 8), which would not have allowed the efficient excitation of the dye-sensitizer throughout the whole film and limited the light harvesting efficiency [20] [23]. The following results will show that a relatively small thickness of NiO is the necessary condition to allow the meaningful comparison of the sensitizing action of the different dyes upon NiO and the analysis of the photoelectrochemical response in the corresponding *p*-DSCs.

Among the commercial dyes here considered (Figure 1) the organic compound SQ2 with its red-shifted and larger absorption with respect to the Ru-based dyes N719 and BD, and to organic ERY B, resulted the most effective dye in terms of sensitization of NiO in the NIR-visible spectrum (Figure 10). The sensitizing effect provided by SQ2 on NiO is also accompanied by the most efficacious action of hole photoinjection in NiO with respect to the other sensitizers upon cell illumination (J-V curves in Figure 11). Data from the characteristic curves of Figure 11 are listed in Table 2. The stronger photoresponse of NiO introduced by its sensitization with SQ2 is ascribed to the generally higher molar extinction coefficient of SQ2 with respect to the Ru-based dyes [37] and, eventually, to the relatively larger amounts of SQ2 dye molecules anchored per unit area of NiO with respect to the other classes of dyes as determined by experiments of absorption/desorption [38].

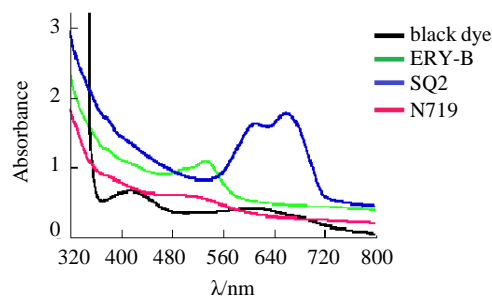


Figure 10. Optical spectra of NiO sensitized with the four different dyes of **Figure 1** (blank: air). NiO film thickness: 0.8 - 1.0 μm .

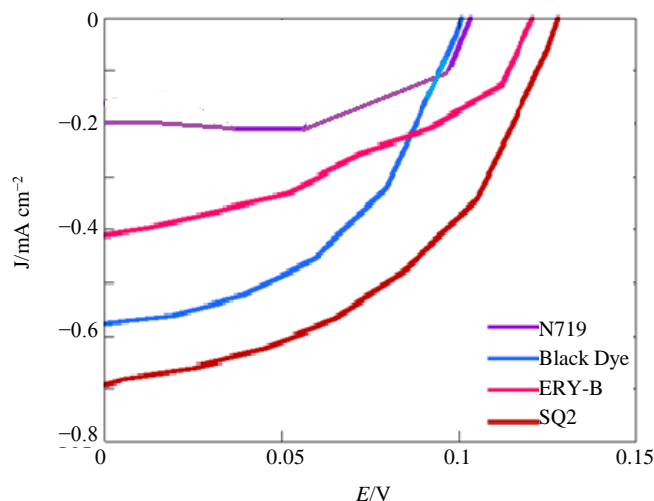


Figure 11. J-V characteristic curves of the *p*-DSCs obtained with the four differently sensitized NiO photocathodes of **Figure 10**. $I_{in} = 8.35 \text{ W}\cdot\text{m}^{-2}$; NiO film thickness: 0.8 - 1.0 μm .

From the general comparison of the photovoltaic performances of the four different dyes it is evident that the organic sensitizers ERY B and SQ2 are those which introduce the largest photovoltages with respect to the Ru-based complexes (**Figure 11** and **Table 1**). This effect is directly associated with the strongest sensitizing effect operated by the two organic dyes with respect to the metal complexes (**Figure 10**). Therefore, we can conclude that the stronger the absorption (**Figure 10**) and the higher the number of absorbed photons per unit time by sensitized NiO, the larger the photopotential of the corresponding *p*-DSC will be (**Figure 11**). As far as the sensitization of NiO with ERY B is concerned, we recall here that the present J-V data (**Table 1**) reproduce quite well our previous results obtained with the *p*-DSCs based on plasma sintered NiO photoelectrodes having similar thickness, and sensitized with the same colorant [23].

These facts can suggest a research guideline about the further optimization of the NiO photovoltaic performance in DSCs: This consists in the synthesis of new dyes having molar extinction coefficients (and probabilities of transition) in the visible-NIR range as high as possible. Another important characteristic of the new dyes has to be the capability of getting anchored on NiO surface in large amounts per surface area. In the monolayer configuration the possible intermolecular aggregation of the anchored dyes with consequent alteration of the absorption spectrum with respect to that of the free molecule, does not seem to be particularly crucial in the action of hole photoinjection in NiO as long as photons are efficiently absorbed. This is particularly clear in case of NiO sensitization with SQ2 dye for which there is spectral evidence of intermolecular aggregation when SQ2 gets anchored on NiO (**Figure 10**). Anyhow, such a phenomenon is not accompanied by a degradation of the photoelectrochemical response since in terms of photocurrent and fill factors the best performances of NiO-based *p*-DSC are just those obtained with SQ2 and BD sensitizers. The cathodic short-circuit photocurrent densities (J_{sc}) are higher than $0.5 \text{ mA}\cdot\text{cm}^{-2}$ for BD and SQ2 whereas ERY B displays $J_{sc} = 0.4 \text{ mA}\cdot\text{cm}^{-2}$ (**Figure 11** and **Table 1**). This implies that the stronger absorption of light from ERY B sensitizer with respect to BD, and

Table 1. List of the parameters derived from the J-V characteristic curves obtained with the *p*-DSCs assembled with NiO photocathodes ($l = 0.8 - 1.0 \mu\text{m}$) and the sensitizers N719, BD, ERY B and SQ2. Electrolyte composition: 0.1 M I_2 , 1.0 M LiI in acetonitrile. η : overall efficiency; V_{oc} : open-circuit voltage; J_{sc} : short circuit current density; FF: fill factor. Sintering time of the NiO sample is 5 min (see *Experimental section*).

Dye	$\eta/\%$	V_{oc}/V	$-J_{sc}/\text{mA}\cdot\text{cm}^{-2}$	FF
N719	0.008	0.103	0.202	0.319
BD	0.027	0.100	0.584	0.391
ERY B	0.022	0.125	0.412	0.358
SQ2	0.041	0.132	0.693	0.376

Table 2. HOMO and LUMO levels of the four dyes here considered for the sensitization of plasma sintered NiO (data taken from Ref. [36]).

Dye	HOMO/eV	LUMO/eV
N719	-5.57	-3.90
BD	-5.20	-3.80
ERY B	-5.69	-3.53
SQ2	-5.31	-3.72

the consequent more efficient hole photoinjection by ERY B vs BD for the build-up of larger photovoltages are not sufficient to produce a correspondingly higher photocurrent through sensitized NiO in *p*-DSCs (**Table 1**). Possible causes for the relatively good performance of BD with respect to ERY B in terms of photocurrent are the higher rate of electron transfer from NiO to the excited (or oxidized) state of BD, the consequent shorter time of hole diffusion from NiO surface, *i.e.* the site of hole generation, towards the bulk of the oxide. Another factor could be also the longer lifetime of the excited state of BD with respect to ERY B, which is involved in the process of electron transfer from the dye (either in the neutral or in the reduced state) to the oxidized form of the redox couple. An analysis of the kinetic factors controlling the transport in sensitized NiO is beyond the scopes of the present paper. The BD anchored to NiO shows a better efficiency of charge transport in comparison to ERY B. At a structural level this fact could be justified with the constant presence of an electron deficient moiety represented by the positively charged ruthenium center during every step of the photocarrier generation and transfer. Ruthenium can be found either in the transient +3 state during the process of hole transfer from the oxide to BD, or in the +2 state in the neutral and in the eventual reduced state of complex BD during the process of electron transfer from the dye to the oxidized form of the redox couple [35]. Such a kinetic driving force for the injection of holes in NiO is not available when organic dyes are the sensitizers. In fact, the strength of the photoaction of the organic sensitizer here considered is mostly based on the relatively higher energies of their LUMO levels with respect to Ru complexes (**Table 2**). This “thermodynamic” factor would favour the electron transfer from the occupied LUMO level of the excited (or reduced) state of the organic dye to the oxidized form of the redox shuttle because of the large stabilization the electron gains in passing from the LUMO level of the excited organic dye to the energy level of the redox couple.

4. Conclusions

Mesoporous nickel oxide (NiO) thin films have been prepared via plasma-assisted rapid discharge sintering (RDS) with microwave heating and were employed as photoactive cathodes in *p*-type dye-sensitized solar cells (*p*-DSCs). RDS NiO films in the pristine state have a grey appearance and present a featureless absorption spectrum in the visible-NIR range. Such an absorption could not be exploited for the photoactivation of any process of charge separation upon irradiation of bare RDS NiO with white light radiation. The voltammograms of RDS NiO in non aqueous electrolyte present two characteristic oxidation peaks that have been ascribed to the oxidation processes Ni(II)→Ni(III) and Ni(III)→Ni(IV) similar to the electrochemical behaviour of NiO in aqueous electrolyte. The scan rate dependence of the peaks intensity in the voltammograms of NiO revealed a linear trend which indicated the confinement of the redox processes of NiO at its external surface in contact with the electrolyte.

Upon sensitization with organometallic (N719, black dye) and organic (squaraine 2, erythrosine B) dyes RDS NiO becomes photoelectrochemically active towards the reduction of triiodide into iodide in the corresponding *p*-DSCs. After comparing the photovoltaic performances of the four *p*-DSCs differing only for the nature of the dye we came into the conclusion that the extent of electronic conjugation in the structure of the sensitizer (or in a part of it), represents the most crucial factor for the control of the photoinjection process consisting in the concomitant transfer of a hole from *p*-type NiO to the oxidized form of the redox shuttle mediated by the excited/reduced dye. This was particularly evident when the effect of sensitization achieved with squaraine 2 was compared with the one produced by erythrosine B. An analogous consideration held when the paragon between the performances of the *p*-DSC based on black dye and the one employing N719 as sensitizers was made.

Acknowledgements

M.A., D.D. and D.P.D. wish to acknowledge the financial support from Science Foundation Ireland (Project No. 07/SRC/B1160). D.D. acknowledges the financial support from the University of Rome “LA SAPIENZA” through the program Ateneo 2012 (Protocol No. C26A124AXX). The research presented in this article was funded by the Deanship of Scientific Research (DSR), King Abdul Aziz University, Jeddah. The author M.A. acknowledges with thanks DSR for financial support.

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